

Silicon Monoxide (SiO) Sputtering Targets

Material Type	Silicon (II) Oxide	Theoretical Density (g/cc)	2.13
Symbol	SiO	Z Ratio	0.87
Melting Point (°C)	>1,702	Sputter	RF, RF-R
Purity:	99.999%, 99.99%, 99.995%	Type of Bond	Indium